

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

SOTOME, Yoshihiro

Atty. Ref.: 900-410

Serial No. 10/038,680

Group: 2825

Filed: January 8, 2002

Examiner: Lee, Calvin

For: METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE AND THE

SEMICONDUCTOR DEVICE MANUFACTURED BY THE METHOD

July 1, 2003

Assistant Commissioner for Patents Washington, DC 20231

Sir:

## **AMENDMENT**

Responsive to the Official Action dated April 2, 2003, please amend the above-identified application as follows:

## **IN THE CLAIMS**

Please substitute the following amended claim(s) for corresponding claim(s) previously presented. A copy of the amended claim(s) showing current revisions is attached.

1. (*Unamended*) A method of manufacturing a semiconductor device comprising steps of:

forming a first metal film having a reducing property on a semiconductor substrate;